

2019/2020 J. S. Lee Memorial Fellowship Programme is now OPEN for Application!

The Programme supports curators, museum professionals and art history research academics taking part in Chinese art related Fellowship at an overseas Programme Participating Institution.

Selected Fellows will have the opportunities to work under leading curatorial professionals, and to participate in curatorial work and research for a period of 4 to 12 months.

Fields of Fellowship supported include Chinese art history, curatorship, archaeology, conservation, museum management and museum education.

The Fellowship fund will cover international round-trip airfare, accommodation and living expense during the Fellowship period.

Check out more: www.jsleefellowship.org

Application deadline: **January 25, 2019**